

Cobalt CHROMIUM

Sputtering Target

NS6130-10-1059

Quick Facts

Product	:	Cobalt Chromium Alloy Sputtering Target
Stock No	:	NS6130-10-1059
Purity	:	99.99%
Molecular Formula	:	Co-Cr

Technical Specification

Diameter	Thickness	Appearance
50 mm \pm 1mm	3 mm \pm 0.5mm	Target

CoCr sputtering targets are valuable materials for the production of thin films with specific properties for various applications in the semiconductor and electronics industries. The unique combination of properties, including hardness, wear resistance, and corrosion resistance, make CoCr a versatile material for use in a range of applications. CoCr sputtering targets have a range of properties, including high hardness, high wear resistance, and good corrosion resistance. They are commonly used in the production of wear-resistant coatings, such as in cutting tools and biomedical implants.

* This image is for graphic purposes only and does not represent the actual product.

